



Attorney Docket No. 0756-7293

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Koichiro TANAKA et al.

Serial No. 10/827,449

Filed: April 20, 2004

For: BEAM HOMOGENIZER, LASER  
IRRADIATION APPRATUS, AND  
METHOD FOR MANUFACTURING  
SEMICONDUCTOR DEVICE

) Group Art Unit: 2874

) Examiner: Michael J. Stahl

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) Asad M. Stampar

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Dear Sir:

The Filing Receipt received in the above-identified application has errors thereon due to Patent Office error as shown in red on the attached copy.

In view of the above, it is requested that a Corrected Filing Receipt be issued.

Respectfully submitted,

Eric J. Robinson  
Eric J. Robinson  
Reg. No. 38,285

Robinson Intellectual Property Law Office, P.C.  
PMB 955  
21010 Southbank Street  
Potomac Falls, Virginia 20165  
(571) 434-6789



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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/827,449	04/20/2004	2874	1790	0756-7293	7	48	9

CONFIRMATION NO. 2793

31780  
 ERIC ROBINSON  
 PMB 955  
 21010 SOUTHBANK ST.  
 POTOMAC FALLS, VA 20165

## FILING RECEIPT



\*OC000000013103624\*

8/28  
 7/2/04

Date Mailed: 06/29/2004

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## Applicant(s)

Koichiro Tanaka, Atsugi, JAPAN;  
 Tomoaki Moriwaka, ~~Atsugi, KOREA, REPUBLIC OF~~  
 Atsugi-shi, Kanagawa-ken, JAPAN

## Assignment For Published Patent Application

Semiconductor Energy Laboratory Co., Ltd., Atsugi-shi, JAPAN;

## Domestic Priority data as claimed by applicant

## Foreign Applications

JAPAN 2003-120782 04/24/2003  
 JAPAN 2003-342803 10/01/2003

If Required, Foreign Filing License Granted: 06/29/2004

Projected Publication Date: 10/28/2004

Non-Publication Request: No

Early Publication Request: No

Title

Beam homogenizer, laser irradiation apparatus, and method for manufacturing semiconductor device

Preliminary Class

385

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